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Supporting information

Structural, Spectroscopic, and Excitonic Dynamic Characterisation in atomically thin Yb³⁺-doped MoS₂, fabricated by femtosecond pulsed laser deposition

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Raman Spectroscopy:



Figure S1: Raman spectra of MoS₂ at excitation wavelength 514 nm: (a) thickness dependent, (b) uniform film thickness measurements.

X-Ray Photoelectron Spectroscopy (XPS):

(a)





Figure S2: XPS of MoS₂: (a) General scan spectra or undoped and YD³⁺ doped MoS₂, (D) Comparison of Molybdenum (Mo) and Sulfer (S) core level XPS data for undoped and Yb³⁺-ion doped MoS₂ films.

The chemical composition and doping were estimated by using X-ray photoelectron spectroscopy (XPS). Figure S2 a-e shows the survey scan, Mo 3d, S2s and S2p regions of the undoped and Yb doped MoS₂ samples. Figure S2 (a) shows the comparison of the general scan spectra of MoS₂ and doped MoS₂. Figure S2 (b) shows the comparison of XPS Mo3d core level spectra of MoS₂ and Yb-doped MoS₂. It is observed that the core level spectra of Mo and S in the MoS₂:Yb sample present a uniform shift towards the lower binding energies by ~0.3-0.4 eV with respect to the

peak position of 2H-MoS₂ of undoped MoS₂. Such a shift in binding energy indicates the change in the chemical microenvironment of doped samples, the Fermi level shift is a clear indication of doping of Yb into Mo lattice. The Mo 3d spectra consist of peaks at around 229.47 eV and 232.54 eV corresponding to Mo4+3d_{5/2} and Mo4+3d_{3/2} spin orbital doublet associated with 2H-MoS₂ phase, respectively. Figure S2b shows the deconvolution of Mo3d spectra of undoped MoS₂ film. The deconvoluted Mo3d spectra of undoped MoS₂ reveal additional peaks which are located at 228.23 eV and 231.44 eV ascribed to 1T-MoS₂ phase, and peaks at 233.18 eV and 235.80 eV associated with the oxidation state. Similarly, the deconvoluted S2p spectra consist of peaks at around 162.19 eV and 163.38 eV corresponding to S 2p_{3/2} and S 2p_{1/2} in undoped MoS₂ film showed in Figure S2 c. Figure S2 d and Figure S2 e show the deconvolution of Mo3d and S 2p of Yb doped MoS₂ films. These films show four distinct features; peaks at 229.05 eV and 232.20 eV corresponding to Mo4+3d5/2 and Mo4+3d3/2 components of 2H-MoS₂, peaks at 227.88 eV and 231.03 eV ascribed to 1T-MoS₂, and peaks at 232.94 eV and 235.67 eV associated with the oxidation states. The deconvoluted S 2p valence spectra (Figure S2 e) of doped MoS2 consist of doublet peaks at around 161.76 eV and 162.94 eV corresponding to S 2p_{3/2}and S 2p_{1/2}, respectively. When the films were compared with respect to other, the peaks shifted to lower binding energies in Yb doped MoS2 than in doped MoS2. The shift may be attributed to the switch from n-type to p-type conductivity with Yb doping. In order to confirm the type of doping, we need further characterizations of the films. [1-3].

 Table S1: Comparison of Mo and S core level binding energy values of undoped and Yb³⁺

 doped MoS2 films.

	2H-MoS₂ BE, eV	1T-MoS₂ BE, eV	1T –MoS ₂ BE, eV	S2s BE, eV	S2p3/2 BE, eV	S2p1/2 BE, eV
MoS2	Mo3d5/2: 229.47 Mo3d3/2: 232.54	Mo3d5/2: 228.23 Mo3d3/2: 231.44	Mo3d5/2: 233.18 Mo3d3/2: 235.80	226.55	162.19	163.38
MoS2:Yb	Mo3d5/2: 229.05 Mo3d3/2: 232.20	Mo3d5/2: 227.88 Mo3d3/2: 231.03	Mo3d5/2: 232.94 Mo3d3/2: 235.67	226.13	161.76	162.94

Table S2: A comparison of the calculated lattice parameters and relative energies of the 2H and 1T allotropes of MoS_2 .

MoS ₂ (bulk)	Space group	a (Å)	c (Å)	Mo-S	ΔΕ
	Crystal			(Å)	(kJ/ mol.fu)
	system				(kJ/mol.atom)
2H	P63/mmc	3.1587	12.0872 (-	2.401	0
	Hexagonal	(+0.1%)	1.4%)		0
1T	P-3m	3.1957	5.6432 (-5.1%)	2.418	+76.1
	Trigonal	(+0.2%)			+25.4

Band structure calculation (Hybrid functional):

The electronic structure of molybdenum disulfide (MoS₂) was analysed through the first principles calculations using density functional theory (DFT) using CASTEP code. DFT is known to significantly underestimate the bandgap in materials; therefore we have used a recent computationally intensive hybrid functional (HSE06) code, which is able to predict the bandgap accurately. Bulk MoS₂ was geometry optimised (dispersion corrected TS-PBE functional) giving a=3.159 A°(~0.1%) and c=1 2.071 A° (~1.8%). A monolayer of MoS₂ was modelled using a supercell with an interplanar (vacuum) distance of 15 A° to avoid interactions between adjacent sheets. DF T calculations accurately predict the expected increase in the bandgap from bulk MoS₂ (~2.27 eV direct). Indirect bandgap of monolayer

MoS₂ lies between point Γ to Γ -K in first Brillouin zone, while the direct bandgap lies in point-K. The indirect and direct bandgap transition observed in MoS₂ when shifted from bulk to monolayer is due to quantum confinement effects [4].



Figure S3: DFT band structure calculations using hybrid functional code, (a) and (b) electronic band structure diagram of bulk and monolayer MoS₂.



Figure S4: The DFT modelled 2H MoS₂ structure, showing (a) trigonal prism, and b) metastable octahedral 1T co-ordination.

Nonlinear Z-scan:

To measure the nonlinear optical response of the thin films, we have employed a conventional open-aperture Z-scan setup which measures the total transmittance as a function of incident laser intensity. In our Z-scan experiment, 120 fs pulses from a Ti-Saphire amplifier was used to excite the sample. The low repetition rate was kept at 1 KHz. The beam was focused by a 20 cm focal length lens, and the sample was moved along the z axis of the beam by using a computer controlled translation stage. The Rayleigh length (Z_0) and the beam waist in our experiment were 1.7 mm and~19 µm, respectively.

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